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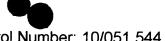
APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/051,544	01/18/2002	Klaus Hummler	01 P 14590 US (8055-115) 9627		
7.	590 02/24/2003				
F. CHAU & ASSOCIATES, LLP Suite 501 1900 Hempstead Turnpike			EXAMINER		
			MONDT, JOHANNES P		
East Meadow,	NY 11554		ART UNIT PAPER NUMBER 2826 DATE MAILED: 02/24/2003		

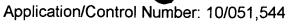
Please find below and/or attached an Office communication concerning this application or proceeding.

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•		Applic	ation No.	Applicant(s)	
Office Action Summary		10/051	,544	HUMMLER, KLAUS	
		Examir	ner	Art Unit	
			es P Mondt	2826	
Period fo	The MAILING DATE of this commun or Reply	ication appears on	the cover sheet with	the correspondence addre	9SS
A SH THE I - Exter after - If the - If NO - Failu - Any r	ORTENED STATUTORY PERIOD F MAILING DATE OF THIS COMMUNI nsions of time may be available under the provisions SIX (6) MONTHS from the mailing date of this comm period for reply specified above is less than thirty (3 period for reply is specified above, the maximum sta re to reply within the set or extended period for reply eply received by the Office later than three months a d patent term adjustment. See 37 CFR 1.704(b).	ICATION. of 37 CFR 1.136(a). In no nunication. 0) days, a reply within the s atutory period will apply and will. by statute, cause the	event, however, may a replicated from thirty (3 at will expire SIX (6) MONTH application to become ABAN	y be timely filed 30) days will be considered timely. S from the mailing date of this comm	nunication.
1)🖂	Responsive to communication(s) fil	ed on 22 January 2	· 2003 .		
2a) 🗌		2b) This action			
3) 🗌	Since this application is in condition closed in accordance with the pract on of Claims	n for allowance exc	ept for formal matte	rs, prosecution as to the n 11, 453 O.G. 213.	nerits is
· ·	Claim(s) <u>1-19</u> is/are pending in the a	opplication			
	4a) Of the above claim(s) <u>1-13</u> is/are	• •	naidaration		
	Claim(s) is/are allowed.	WILLIGIAWH FOR CO	nsideration.		
	Claim(s) <u>14-19</u> is/are rejected.				
	Claim(s) is/are objected to.				
	Claim(s) are subject to restrict	tion and/or alaction	roquiroment		
	on Papers	non ana/or election	requirement.		
9)[] 7	he specification is objected to by the	Examiner.			
10)∐ Т	he drawing(s) filed on is/are:	a) accepted or b)	objected to by the	Examiner.	
	Applicant may not request that any obje	ection to the drawing(s) be held in abeyance	e. See 37 CFR 1.85(a).	
11)∐ T	he proposed drawing correction filed	l on is: a)☐	approved b)⊡ disa	pproved by the Examiner.	
	If approved, corrected drawings are req		Office action.		
	he oath or declaration is objected to	by the Examiner.			
Priority u	nder 35 U.S.C. §§ 119 and 120				
_	Acknowledgment is made of a claim i	for foreign priority u	ınder 35 U.S.C. § 1	19(a)-(d) or (f).	
a)[All b) Some * c) None of:				
•	1. ☐ Certified copies of the priority of t				
	2. Certified copies of the priority of				
	B. ☐ Copies of the certified copies o application from the Interna ee the attached detailed Office action	ational Bureau (PC)	Γ Rule 17.2(a)).		ge
	cknowledgment is made of a claim fo				olication).
a)	☐ The translation of the foreign lang cknowledgment is made of a claim fo	guage provisional a	pplication has been	received.	
Attachment(33	· · · · · · · · · · · · · · · · · · ·	
	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PT	O-948)		mary (PTO-413) Paper No(s) mal Patent Application (PTO-15	

2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)

6) Other:





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DETAILED ACTION

Election/Restrictions

1. Applicant's election with traverse of Group II, claims 14-19, in Paper No. 3 is acknowledged. The traversal is on the ground(s) that while Applicant does not take issue with the shown distinctness of the invention and does not seem to take issue with the assertion by the examiner that the inventions of Group I and Group II are distinct, "applicant believes simultaneous examination will not present an undue burden". In support of this statement, Applicant mentions that "one is directed" to class 257 in class 438 vice versa. This is not found persuasive because although directions in the Classification Search page to which Applicant may refer here are useful, they do not in any way lighten the task of having to actually search the necessary subclasses.

The requirement is still deemed proper and is therefore made FINAL.

Claim Objections

 Claims 15 -19 are objected to because of the following informalities: Claims 15-18 should refer to claim 14 instead of to claim 15; claim 19 should refer to claim 18 instead of to claim 19. Appropriate correction is required.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:





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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. *Claims 14-19* are rejected under 35 U.S.C. 103(a) as being unpatentable over Vallett (6,078,057) in view of Goruganthu et al (6,277,659).

Vallett teaches (cf. Figure 3)a memory device (cf. column 3, lines 45-67) having accessible source (cf. column 2, lines 16-27) such that device parameters can be determined, comprising:

a thinned back-side of a semiconductor substrate of the device (cf. column 4, lines 21-29);

a trench 12 (cf. column 4, lines 29-33) milled from said thinned back-side exposing a portion of a vertical trench fill 8 (cf. column 4, lines 37-41); and

a conductive material (contact-mode with conductive tip) connecting the vertical trench fill and a source of the device (cf. column 4, lines 37-41).

Vallett does not necessarily teach to thin that part or at least a general neighborhood that part of the back-side of said semiconductor substrate in which said trench 12 is to be milled by an amount that exceeds the amount of thinning carried out elsewhere on the back-side of said semiconductor substrate, i.e., a dimple ground into said back-side of said semiconductor substrate of said memory device.

However, as is witnessed by Goruganthu et al, it is understood in the art of testable semiconductor devices that the thinning only serves a purpose in the general area where said trench 12 is to be milled while standard laser technology is available



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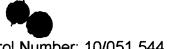
through which local thinning is effected, inter alia for the purpose of testing (cf. title, abstract, column 1, lines 60-65 and column 4, lines 45-50).

Motivation to include the teaching by Goruganthu et al in the invention by Vallett stems from the increased cost effectiveness achieved in aiming the thinning procedure at the area to be tested, rather than the entire back-side area. Combination of the aforementioned teaching with the invention by Vallett is especially straightforward, because exactly the same principle, relying on the detection of laser heating of interconnects, can be employed in the device by Vallett as in Goruganthu et al for determining the area to be thinned (cf. column 4, lines 50-60). Success in the implementation of said combination can therefore be reasonably expected.

With regard to claim 15: the trench 12 as taught by Vallett is milled into a portion of the vertical trench fill 8 (cf. column 4, lines 37-41).

With regard to claims 16-17: the conductive material is at the back side of the semiconductor substrate (cf. column 4, lines 37-41), and therefore both materially and functionally can be called a back-side electrode (claim 16) while covering a portion of the back-side of the semiconductor substrate by virtue of the inherent property of spatial extension of the conductive tip (cf. column 4, lines 37-41).

With regard to claims 18-19: the device of claim 15 is definite by virtue of the description of its attributes. The further limitations as defined by claims 18 and 19 do not further limit said device of claim 15.



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Conclusion

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure: Vallett (5,990,562); Vallett (US 2001/0006233 A1).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Johannes P Mondt whose telephone number is 703-306-0531. The examiner can normally be reached on 8:00 - 18:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan J Flynn can be reached on 703-308-6601. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

JPM February 15, 2003

